

Supporting Information

Anion-cation synergistic doping strategy on Ga₂O₃ scaffold for improving electron extraction and transport in CH₃NH₃PbCl₃-based photodetector

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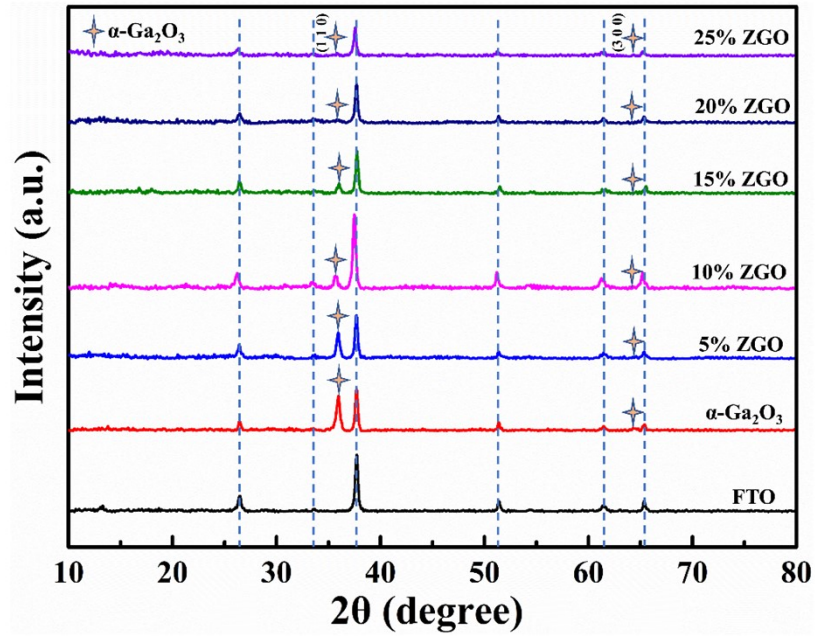


Fig. S1 XRD pattern of 5%-25% Zn(Ac)₂-doping α -Ga₂O₃ nanorods, and FTO substrate as well as pristine α -Ga₂O₃ nanorods for comparison.

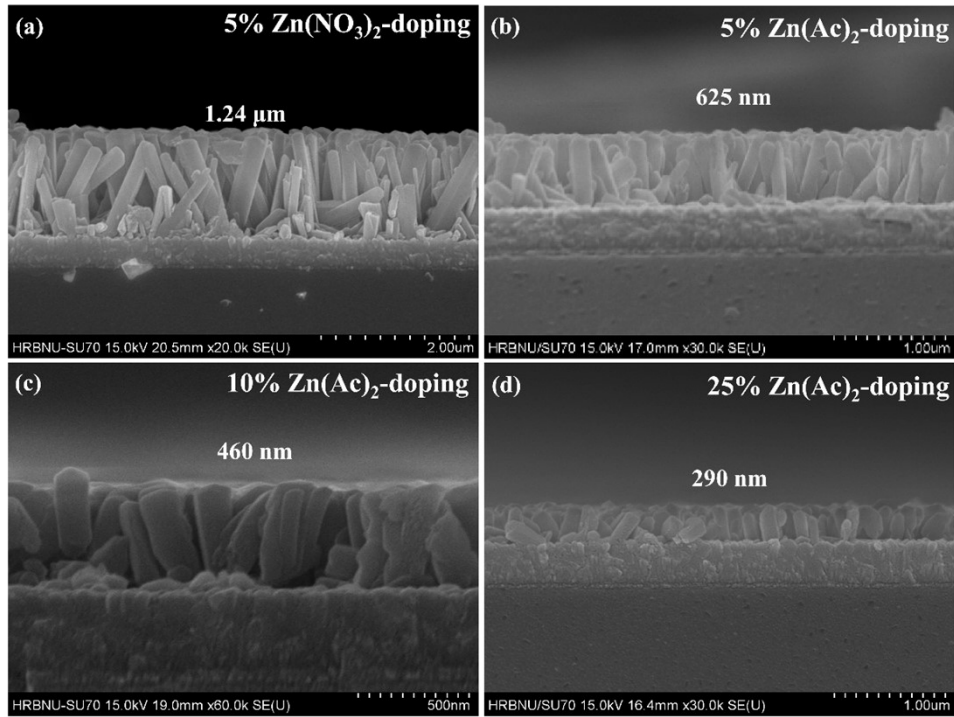


Fig. S2 (a) Cross-sectional SEM image of ZGO nanorods with 5% Zn(NO₃)₂-doping. (b)-(d) Cross-sectional SEM images of ZGO nanorods with 5%,10%, 25% Zn(Ac)₂-doping, respectively.

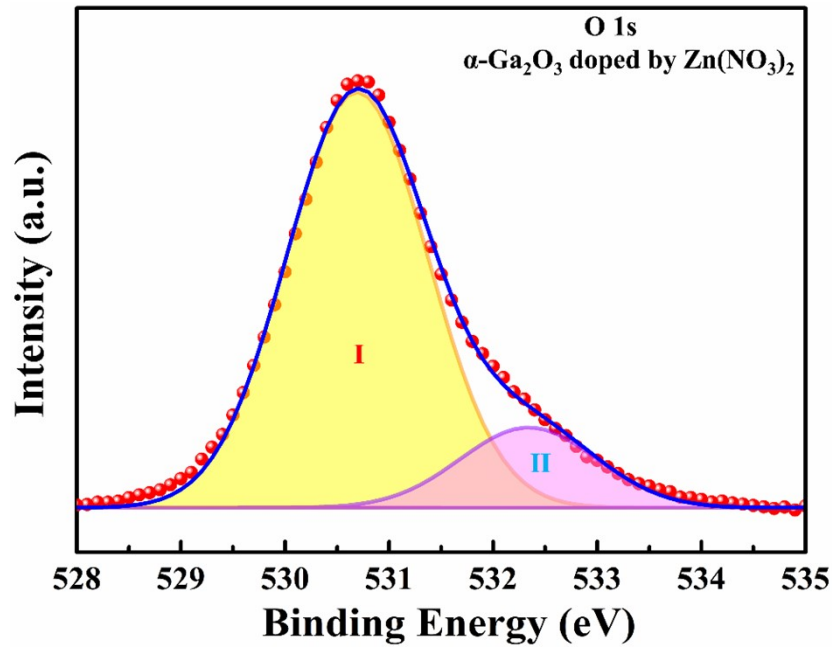


Fig. S3 XPS core-level spectrum of O 1s in the α -Ga₂O₃ nanorods doped by 5% Zn(NO₃)₂.

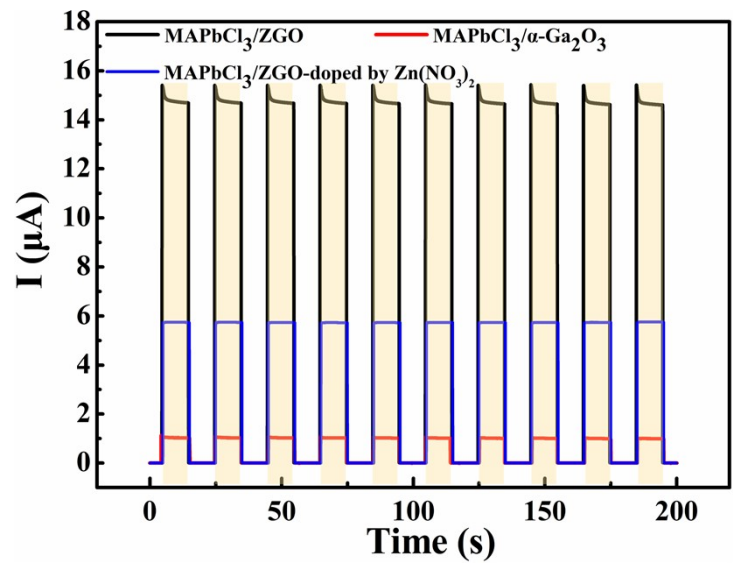


Fig. S4 I-t curves of the polycrystalline MAPbCl₃/α-Ga₂O₃, polycrystalline MAPbCl₃/ZGO, and polycrystalline MAPbCl₃/ZGO-doped by Zn(NO₃)₂ devices.

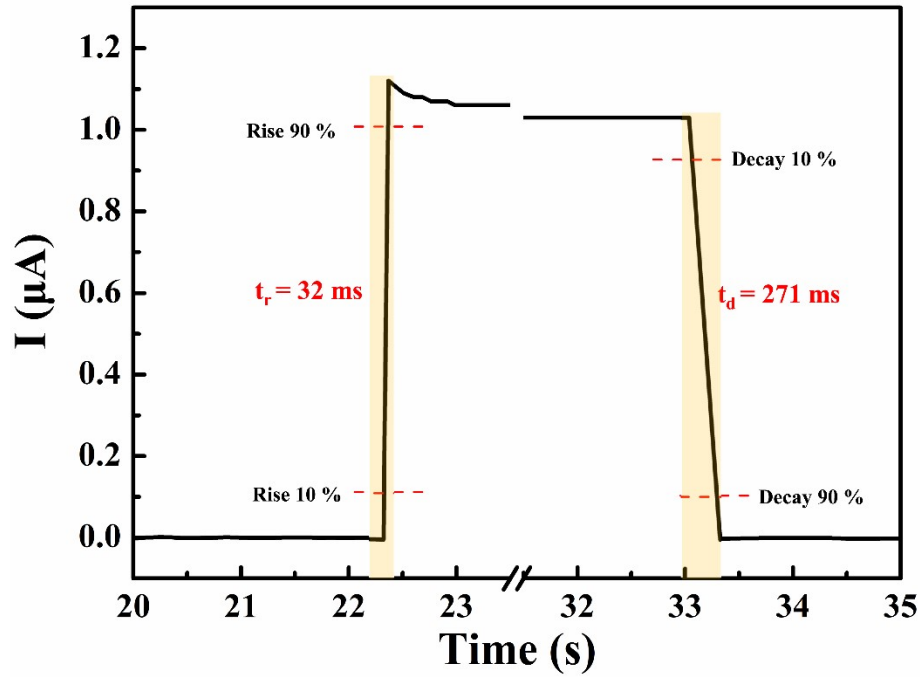


Fig. S5 Response time of the polycrystalline MAPbCl₃/α-Ga₂O₃ device.

In the SCLC curves, the dark current is almost linearly dependent on the applied voltage in the low voltage region, indicating an Ohmic region. Then, the current increases quickly in the intermediate voltage region, reflecting the trap-filling limited (TFL) region. This is relevant to the complete filling of the trap states by the injected charge carriers. At higher bias, the current shows a quadratic dependence ($I \propto V^2$) fitting with the Mott-Gurney law:

$$J_d = \frac{9\varepsilon\varepsilon_0\mu V^2}{8L^3}$$

where J_d is the current density, V is the applied voltage, L is the thickness of the perovskite, ε is the relative dielectric constant of MAPbCl₃ and ε_0 is the vacuum permittivity. The quadratic dependence region is defined as SCLC region, where the carrier mobility is determined. To investigate the electron mobility, the electron-only devices are prepared respectively in the polycrystalline MAPbCl₃/α-Ga₂O₃ device and MAPbCl₃/ZGO device. According to the above equation, the electron mobilities are determined to be $4.95 \times 10^{-3} \text{ cm}^2 \text{ V}^{-1} \text{ S}^{-1}$ in the polycrystalline MAPbCl₃/α-Ga₂O₃ device.

The corresponding value is $6.12 \times 10^{-3} \text{ cm}^2 \text{ V}^{-1} \text{ S}^{-1}$ in the MAPbCl₃/ZGO device, which is slightly increased than the pristine device.

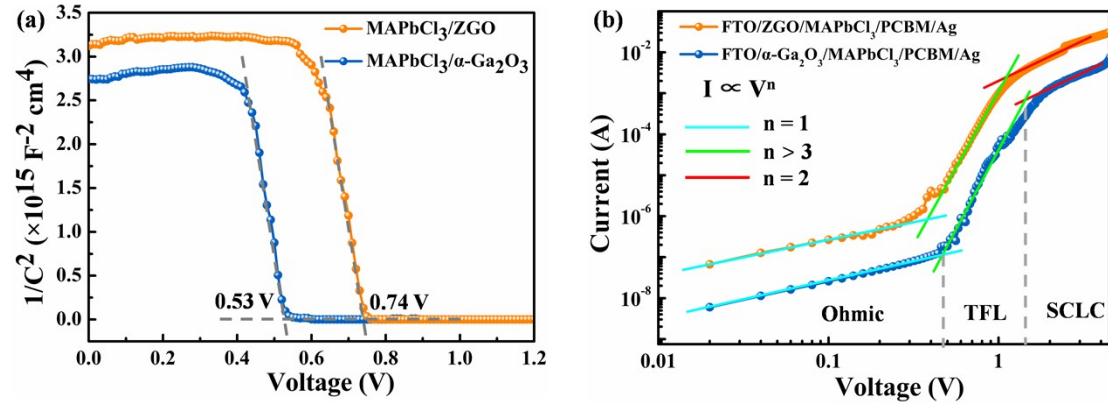


Fig. S6 (a) Mott-Schottky curves and (b) SCLC curves of the polycrystalline MAPbCl₃/α-Ga₂O₃ device and polycrystalline MAPbCl₃/ZGO device.

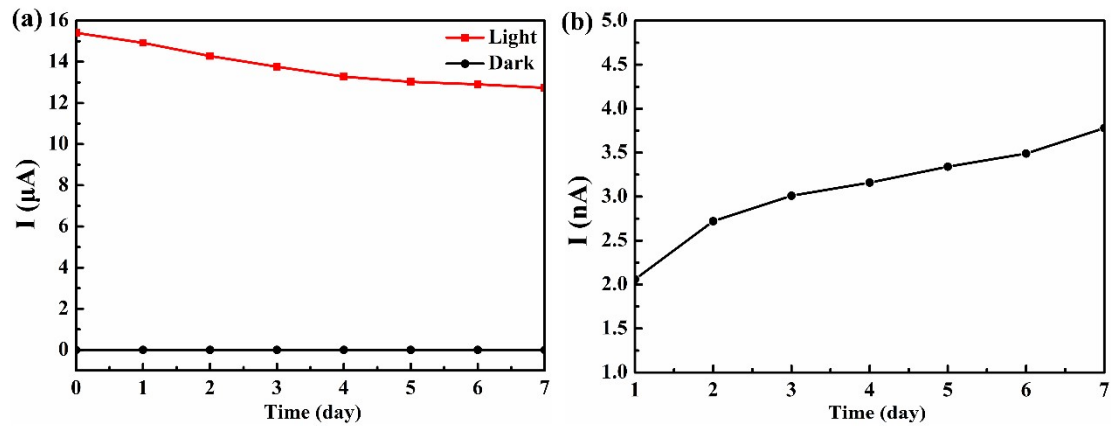


Fig. S7 (a) Stability test with the polycrystalline MAPbCl₃/ZGO photodetector stored in air at a temperature of 25°C and a humidity of 20-30%. (b) The changes of dark current in an enlarged image.

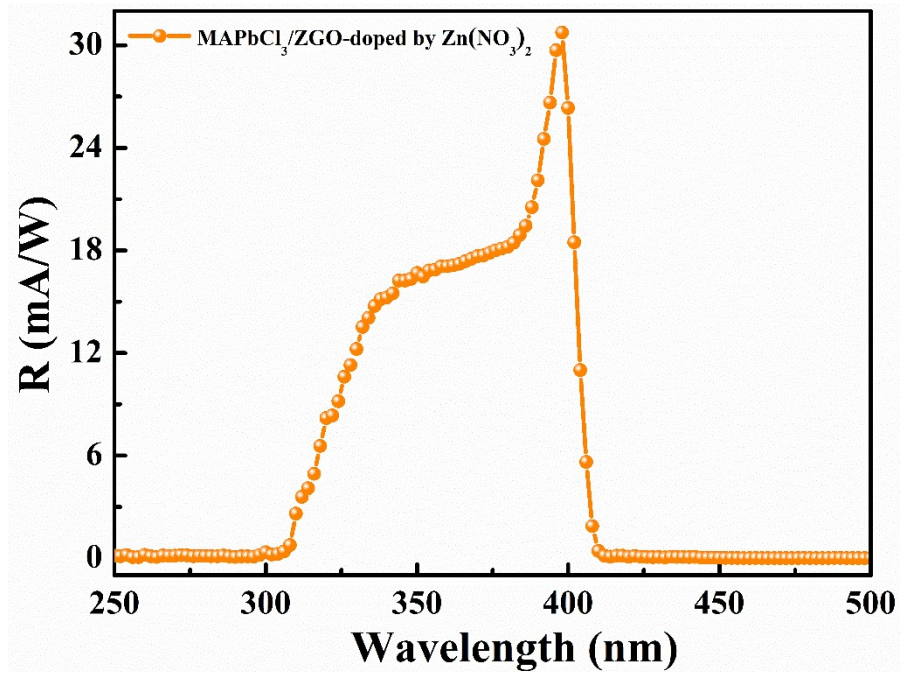


Fig. S8 Responsivity of the polycrystalline MAPbCl₃/ZGO (doped by Zn(NO₃)₂) device under zero bias.

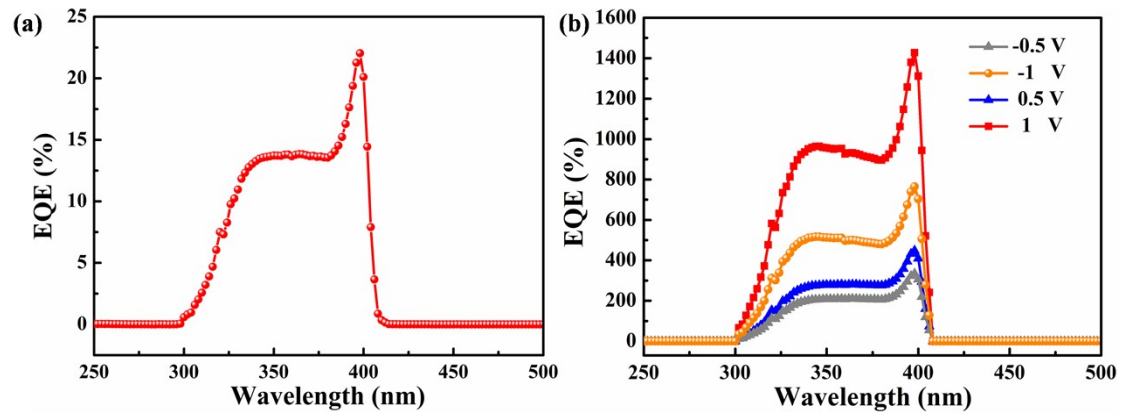


Fig. S9 EQE of the polycrystalline MAPbCl₃/ZGO device under (a) zero bias, and (b) -1 V, -0.5 V, 0.5 V, 1V.